

Serial No.: Not Assigned
Inventor: Scott J. DeBoer et al.

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of:
Scott J. DeBoer et al.

Serial No.: Not Assigned

Filed: February 24, 2004

For: **DOUBLE SIDED CONTAINER PROCESS
USED DURING THE MANUFACTURE
OF A SEMICONDUCTOR DEVICE**

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§ GAU: Not Assigned
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§ Examiner: Not Assigned
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§ Docket #: 1999-1335.01/US
§
§ Paper No. *
§
§

Mail Stop Patent Application
Commissioner for Patents
P.O. Box 1450
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INFORMATION DISCLOSURE STATEMENT

In compliance with the duty of disclosure under 37 CFR §1.56, Applicant respectfully requests that this Information Disclosure Statement be entered and that the references listed on the attached Form PTO-1449 be considered by the Examiner and made of record. As the cited references are cumulative from the parent application from which this application claims priority, copies of the cited references are not included except for US Patent Application Serial No. 09/765,885, filed January 16, 2001, which was cited in the parent as a co-pending application.

In accordance with 37 CFR §1.97(g), this Information Disclosure Statement is not to be construed as a representation that a search has been made or that no other possible material information as defined in 37 CFR §1.56(a) exists.

The following references are submitted for the Examiner's review:

U.S. Patents

U.S. Patent No.	Issue Date	Inventor
4,656,732	04/14/1987	Teng et al.
5,338,700	08/16/1994	Dennison et al.
5,401,681	03/28/1995	Dennison
5,834,845	11/10/1998	Stolmeijer
5,843,830	12/01/1998	Graettinger et al.
5,844,771	12/01/1998	Graettinger et al.
5,869,861	02/09/1999	Chen
5,956,594	09/21/1999	Yang et al.
5,989,952	11/23/1999	Jen et al.
6,046,093	04/04/2000	DeBoer et al.
6,100,137	08/08/2000	Chen et al.
6,127,260	10/03/2000	Huang
6,140,172	10/31/2000	Parekh
6,168,984	01/02/2001	Yoo et al.
6,187,624	02/13/2001	Huang
6,221,711	04/24/2001	Roberts et al.
6,251,726	06/26/2001	Huang
6,300,191	10/09/2001	Yu et al.
6,507,064	01/14/2003	Tang et al.

Other References

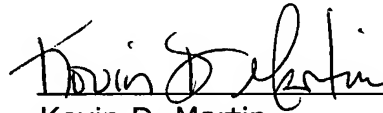
Related application entitled: "REDUCED ASPECT RATIO DIGIT LINE CONTACT PROCESS FLOW USED DURING THE FORMATION OF A SEMICONDUCTOR DEVICE", by Brent A. McClure, Micron Technology, Inc., Serial No. 09/765,885, filed January 16, 2001.

As this information is being submitted within three months of the date of filing of the application, Applicants understand that no fee or certification is required for the submission and consideration of this information at this time.

If there are any matters which may be resolved or clarified through telephone interview, the Examiner is respectfully requested to contact Applicants' undersigned agent at the number indicated.

* * * *

Respectfully submitted,

A handwritten signature in black ink, appearing to read "Kevin D. Martin", is written over a horizontal line.

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FORM: PTO-1449 (REV: 7-80)	U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE	Atty Docket No: 1999-1335.01/US	Serial No: Not Assigned
INFORMATION DISCLOSURE STATEMENT BY APPLICANT (37 CFR 1.98(b)) <i>(use several sheets if necessary)</i>		Applicant: Scott J. DeBoer et al.	
		Filing Date: February 24, 2004	Group: Not Assigned

U.S. PATENT DOCUMENTS

Examiner Initial	Document Number	Date	Name	Class	Subclass	
	AA	4,656,732	04/14/1987	Teng et al.	438	639
	AB	5,338,700	08/16/1994	Dennison et al.	437	60
	AC	5,401,681	03/28/1995	Dennison	437	60
	AD	5,834,845	11/10/1998	Stolmeijer	257	752
	AE	5,843,830	12/01/1998	Graettinger et al.	438	396
	AF	5,844,771	12/01/1998	Graettinger et al.	361	303
	AG	5,869,861	02/09/1999	Chen	257	306
	AH	5,956,594	09/21/1999	Yang et al.	438	396
	AI	5,989,952	11/23/1999	Jen et al.	438	253
	AJ	6,046,093	04/04/2000	DeBoer et al.	438	396
	AK	6,100,137	08/08/2000	Chen et al.	438	253
	AL	6,127,260	10/03/2000	Huang	438	253
	AM	6,140,172	10/31/2000	Parekh	438	238
	AN	6,168,984	01/02/2001	Yoo et al.	438	239
	AO	6,187,624	02/13/2001	Huang	438	253
	AP	6,221,711	04/24/2001	Roberts et al.	438	239
	AQ	6,251,726	06/26/2001	Huang	438	253
	AR	6,300,191	10/09/2001	Yu et al.	438	253
	AS	6,507,064	01/14/2003	Tang et al.	257	306

FOREIGN PATENT DOCUMENTS

Examiner Initial	Document Number	Date	Country	Class	Subclass	Translation Yes	No
	AT					<input type="checkbox"/>	<input type="checkbox"/>
	AU					<input type="checkbox"/>	<input type="checkbox"/>

Initial

OTHER REFERENCES (including author, title, date, pertinent pages, etc.)

AV		Related application entitled: "REDUCED ASPECT RATIO DIGIT LINE CONTACT PROCESS FLOW USED DURING THE FORMATION OF A SEMICONDUCTOR DEVICE", by Brent A. McClure, Micron Technology, Inc., Serial No. 09/765,885, filed January 16, 2001.
AW		
AX		

Examiner:	Date Considered:
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EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication with applicant.